



**photonics**  
precision engineering

## Tolerancing Metalenses: from a Classical Perspective

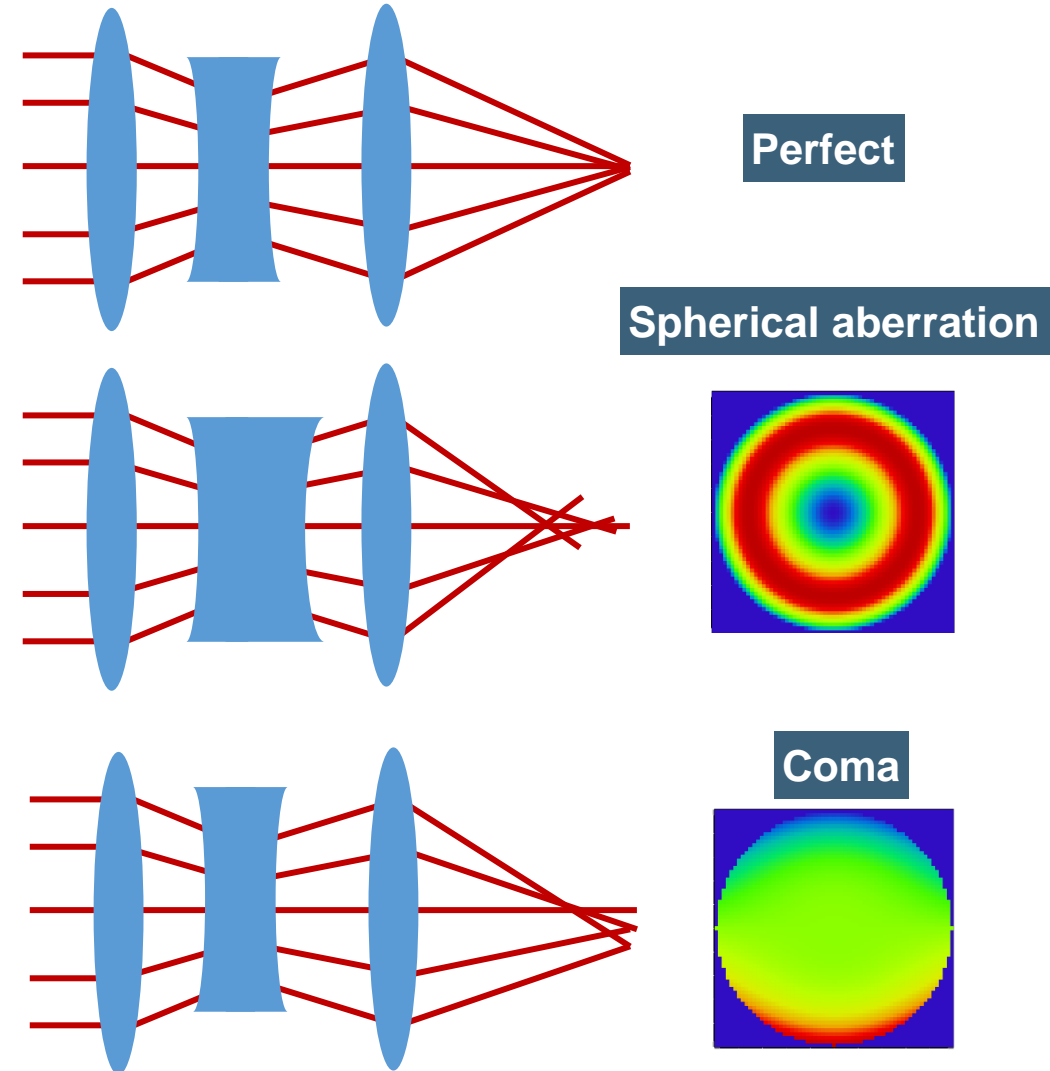
Dominik Schulz | 12.05.2023

EPIC Meeting on Photonics for AR/VR/MR

# What are Metalenses and how are they different?

## Review of classical tolerancing

- Classical optical systems have mostly spherical elements due to manufacturing reasons
- Perturbations in light interaction parameters cause small changes in the wavefront
- Deviations from spherical shape can be expressed in a polynomial expansion
- Changes in low-frequency properties lead to low-frequency changes in the wavefront
- Higher-order contributions quickly vanish when describing perturbations in ascending order of pupil coordinates
- Zernike polynomials are an appropriate choice for these polynomials



# What are Metalenses and how are they different? Does this suffice?

- Zernike polynomials identify potential origins for specific aberrations and countermeasures, e.g.:
  - on-axis spherical aberration, symmetrical off-axis astigmatism, field curvature, ...  
Compensated by → airspaces
  - on-axis coma, asymmetric off-axis astigmatism, ... Compensated by → lateral shifting of elements
- Perturbative description of aberrations helps choose compensators

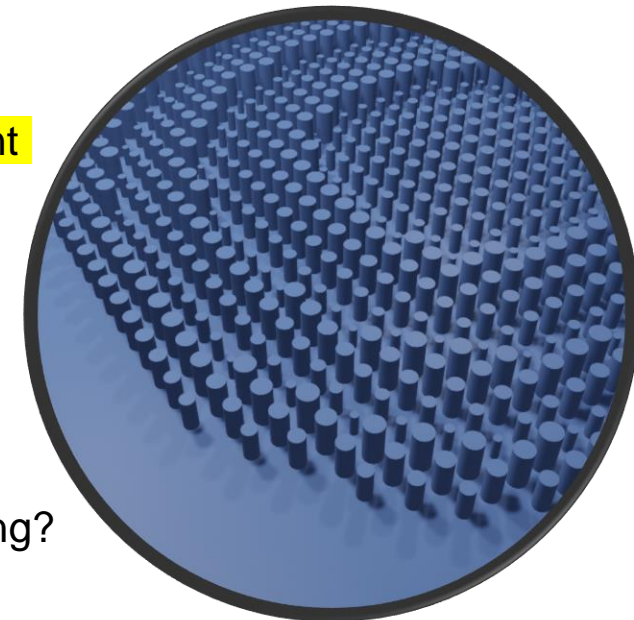
## in short

- Describing aberrations in a perturbative manner is useful due to spherical nature of surfaces
- Using Zernike polynomials allows understanding sensitivity of system and deriving adjustment strategies

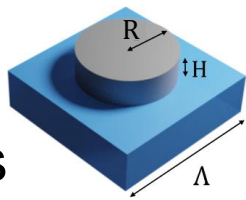
## what changes with metalenses?

- Metalenses generate spherical wavefront by different action principles
- Manipulation of phase and amplitude by small sub-wavelength units (metaatoms)
- The question is:  
Action principle is significantly different → classical approach to tolerancing still working?

**If not, what alternatives do we have?**



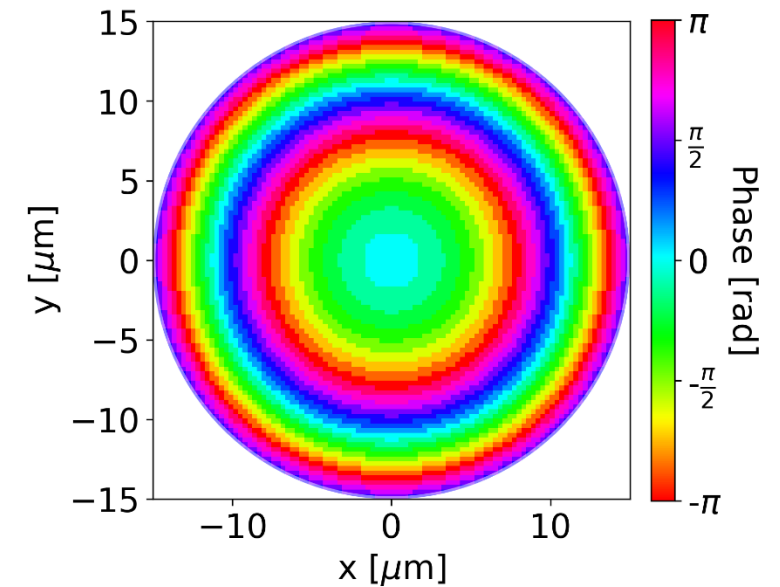
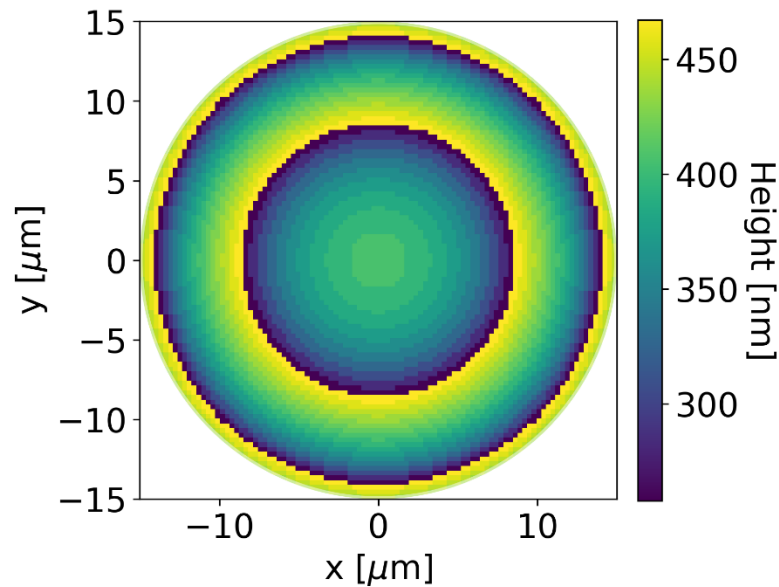
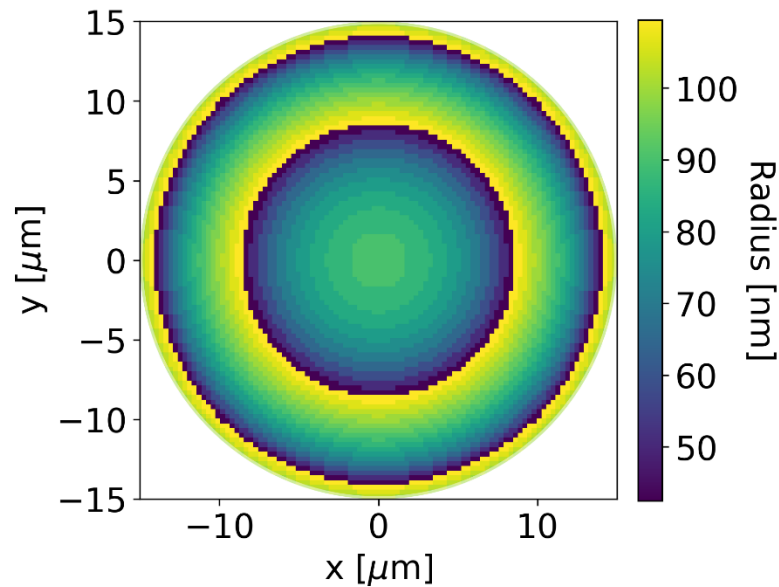
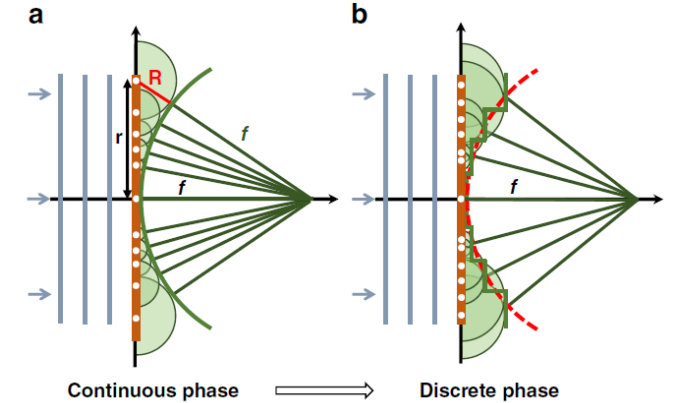
# Simple example: Cylindrical metaatoms



- More degrees of freedom → more possibilities for error correction
- Breaking symmetry → selectivity for polarization, enantiomeric sensing, ...

## Here:

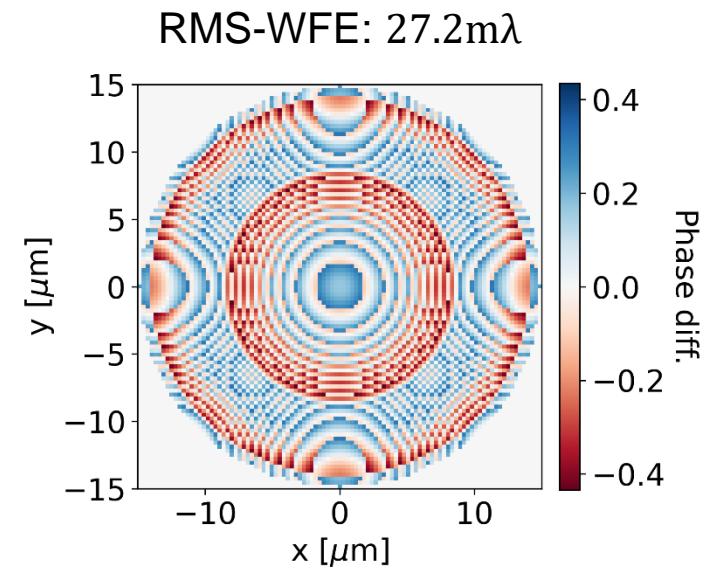
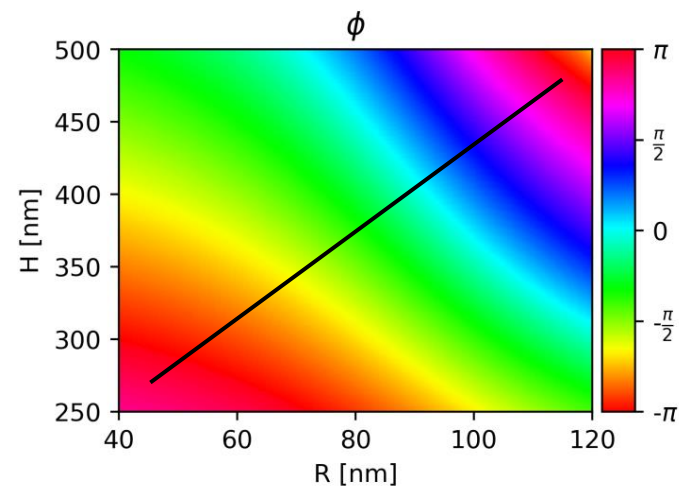
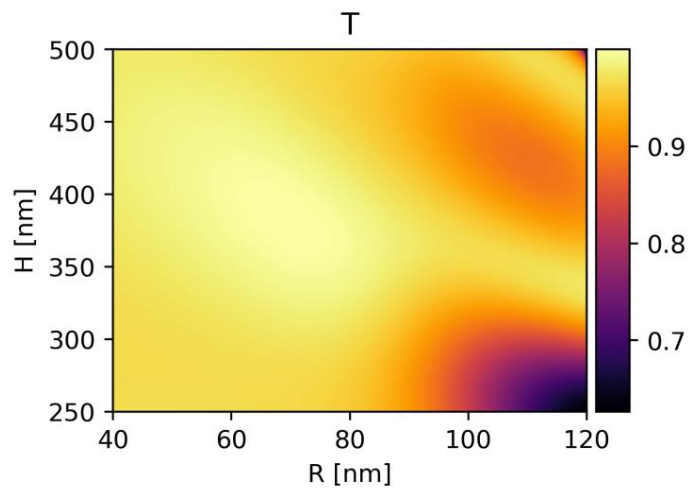
- 2 degrees of freedom with axial symmetry: Radius and height
- Dielectric low-NA metalens →  $NA = 0.15, \lambda = 633\text{nm}, \text{TiO}_2 \text{ on SiO}_2$
- 16 phase levels go with radius and height



# Tolerance effects (simple design): Effect of systematic offset

What happens including errors in fabrication?

- Offset of radius and height by +5nm and +10nm homogeneously
- Simple setup with linear dependence on parameters (ideal for offset)
- What measure for tolerances?

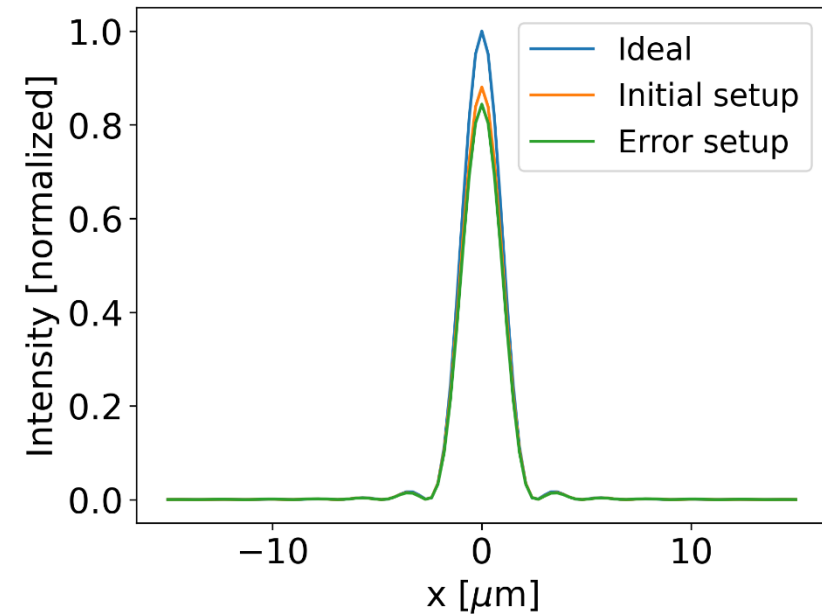
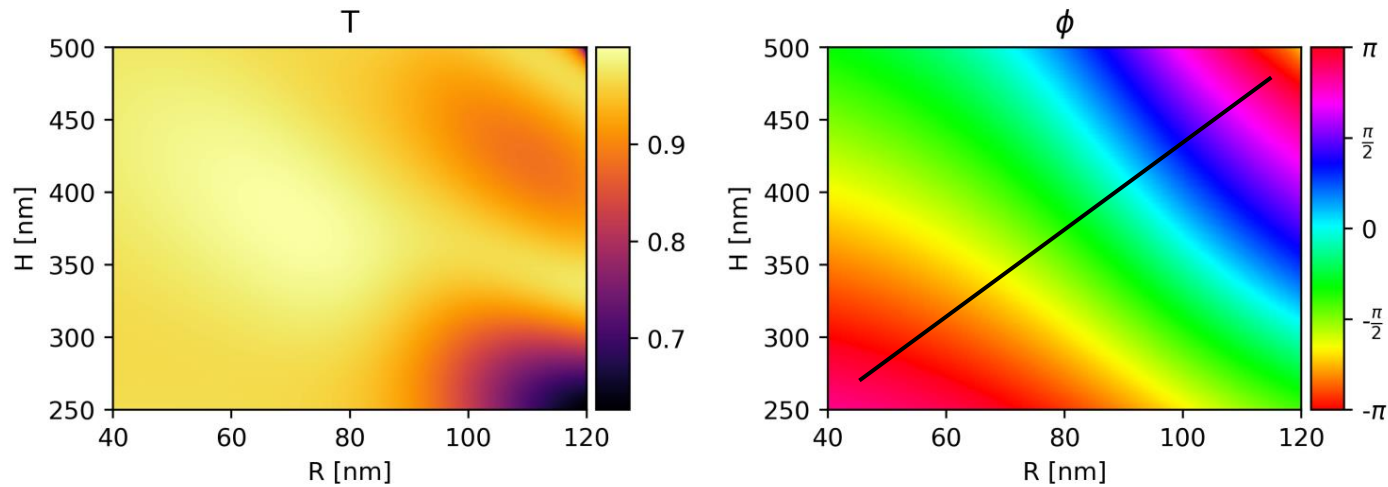


**→ Low Zernikes not sufficient  
(Residuum too high)**

# Tolerance effects (simple design): Effect of systematic offset

What happens including errors in fabrication?

- Offset of radius and height by +5nm and +10nm homogeneously
- Simple setup with linear dependence on parameters (ideal for offset)
- What measure for tolerances?



**→ PSF and Strehl ratio better measure for error**  
**→ Propagation of “full” field**

How to improve?

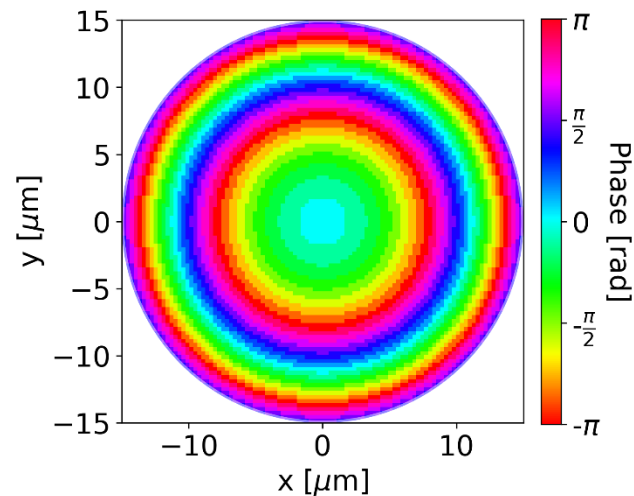
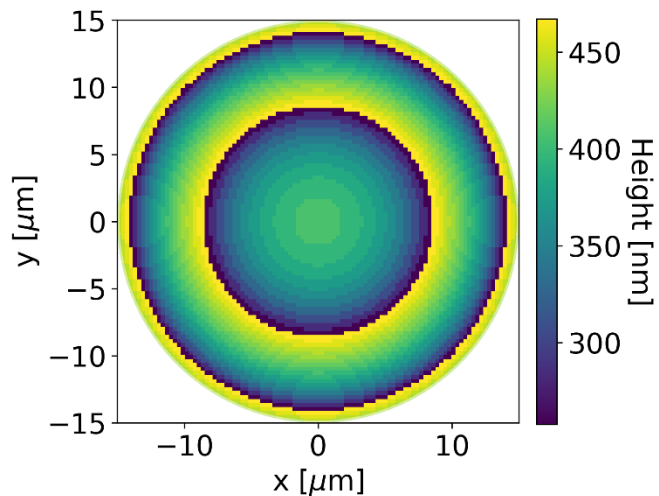
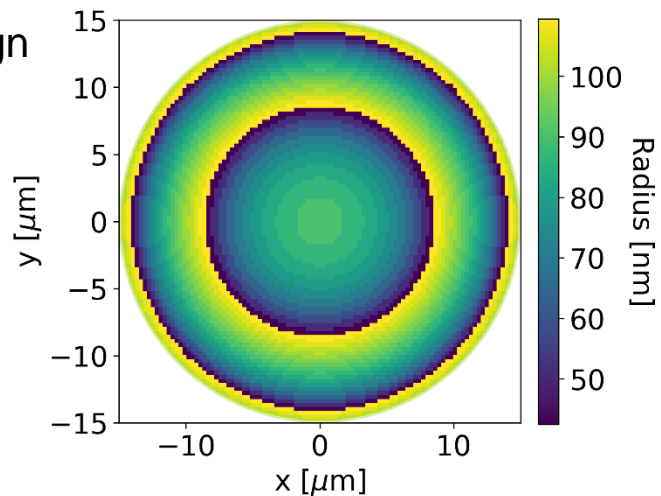
- Consider tolerances already in design of metaatoms library
- Design towards insensitivity to systematic or random errors (offset, scaling, merging, ...)
- Assume linear dependence on parameter in phase space
  - Small gradient  $\rightarrow$  less change in amplitude and phase by parameters
- Strong change of hypersurface (resonances)  $\rightarrow$  finite difference not sufficient
- Minimize loss-function with automatic differentiation for gradient

$$\mathcal{L}(\Theta) = w_1 (1 - \cos \phi(\Theta) \cos \phi_t - \sin \phi(\Theta) \sin \phi_t) + w_2 (T(\Theta) - 1)^2 + w_3 \|\delta\Theta \circ \nabla_{\Theta} \phi(\Theta)\|_2^2 + w_4 \|\delta\Theta \circ \nabla_{\Theta} T(\Theta)\|_2^2$$

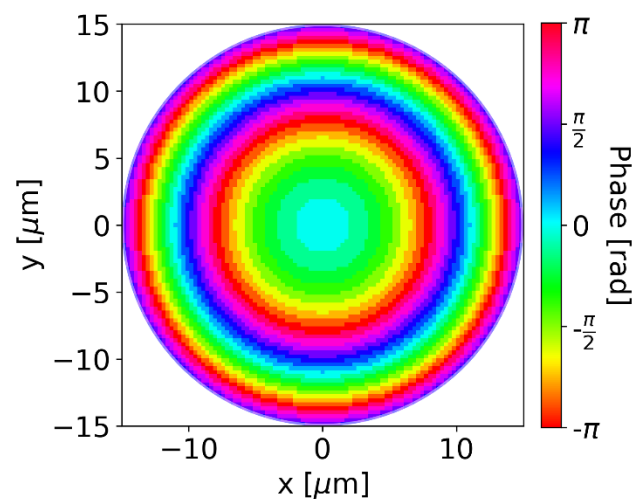
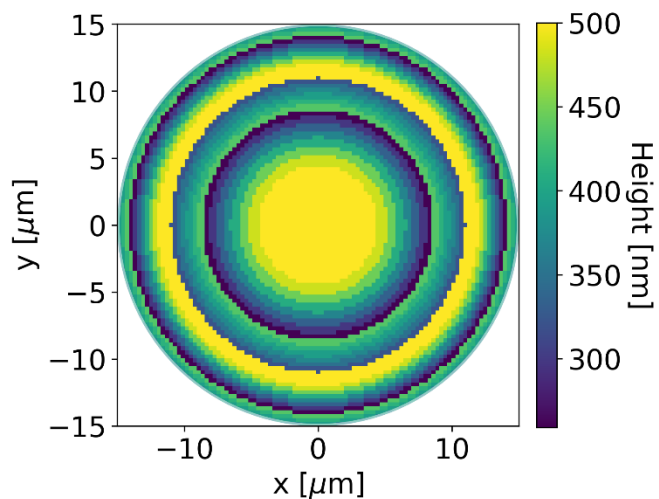
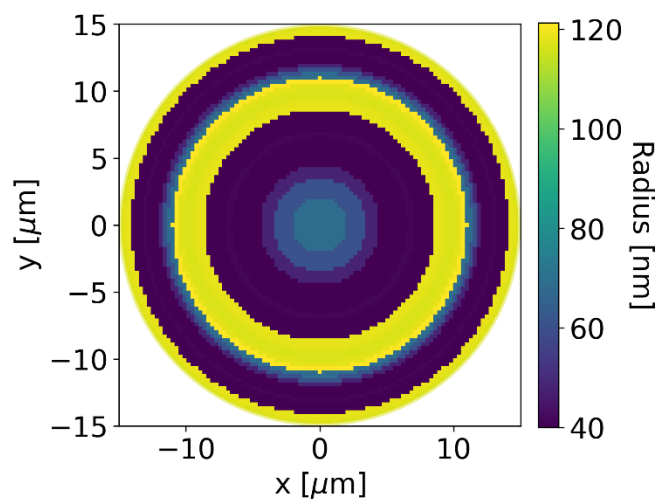
- Only rough measure for system performance
  - $\rightarrow$  Simulation of full wavefront or supercell for resonance analysis

# Tolerance effects: Stable design

### Simple design



### New Design after optimization

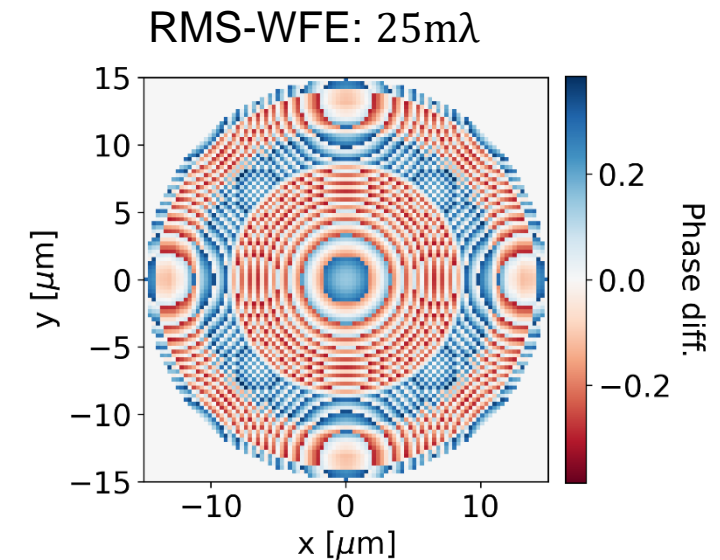
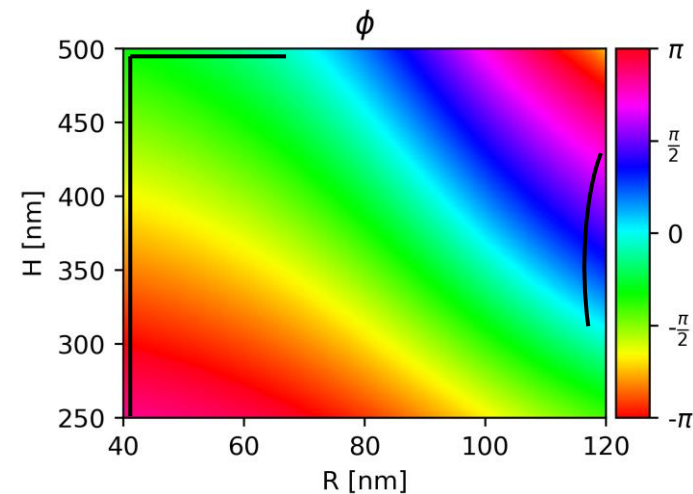
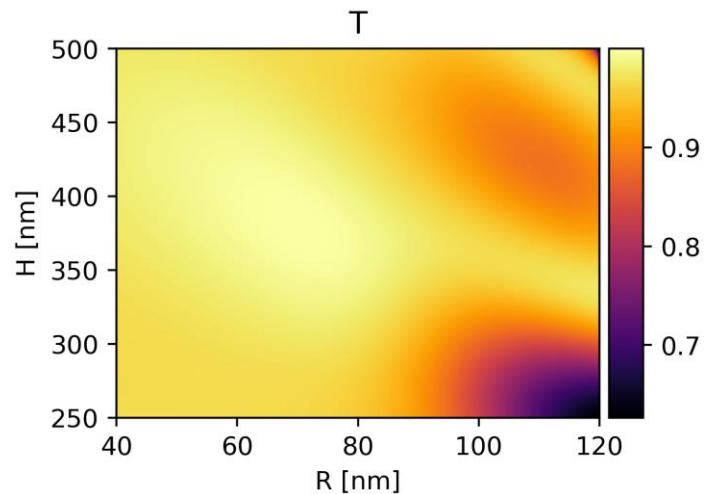




# Tolerance effects: Effect of systematic offset

What happens including errors in fabrication?

- Offset of radius and height by +5nm and +10nm homogeneously
- Optimized parameter set for metaatom library



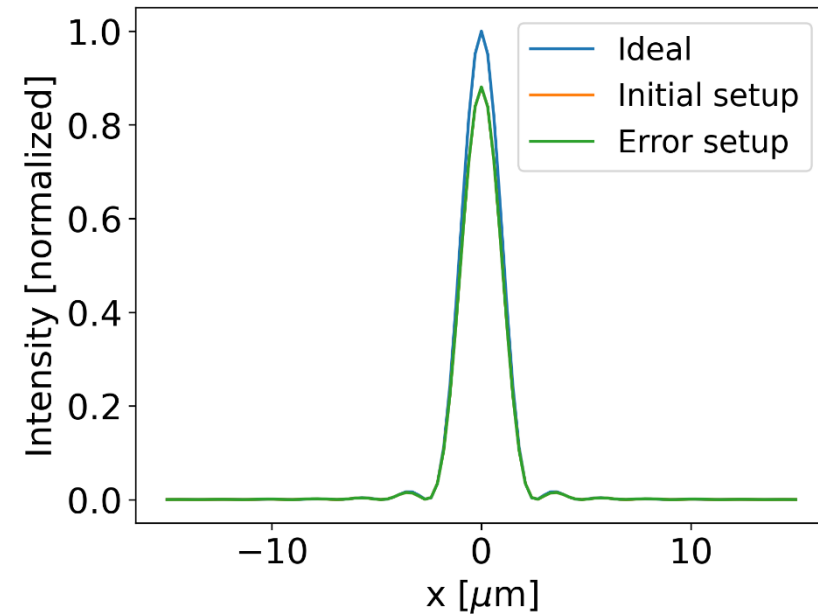
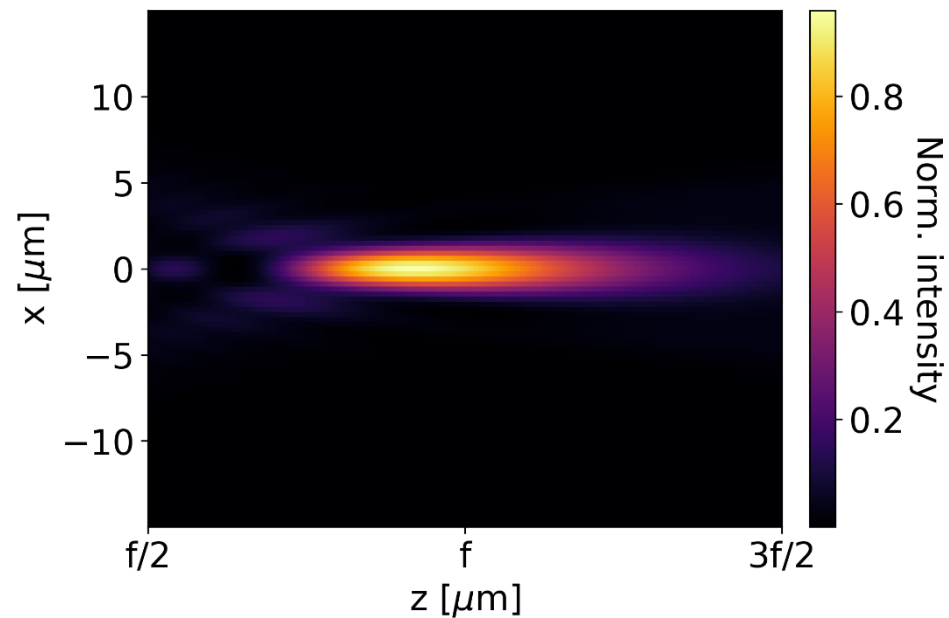
→ Less error in lower Zernikes  
(Residuum smaller)

# Tolerance effects: Effect of systematic offset

What happens including errors in fabrication?

- Offset of radius and height by +5nm and +10nm homogeneously
- Optimized parameter set for metaatom library
- Gradient optimization

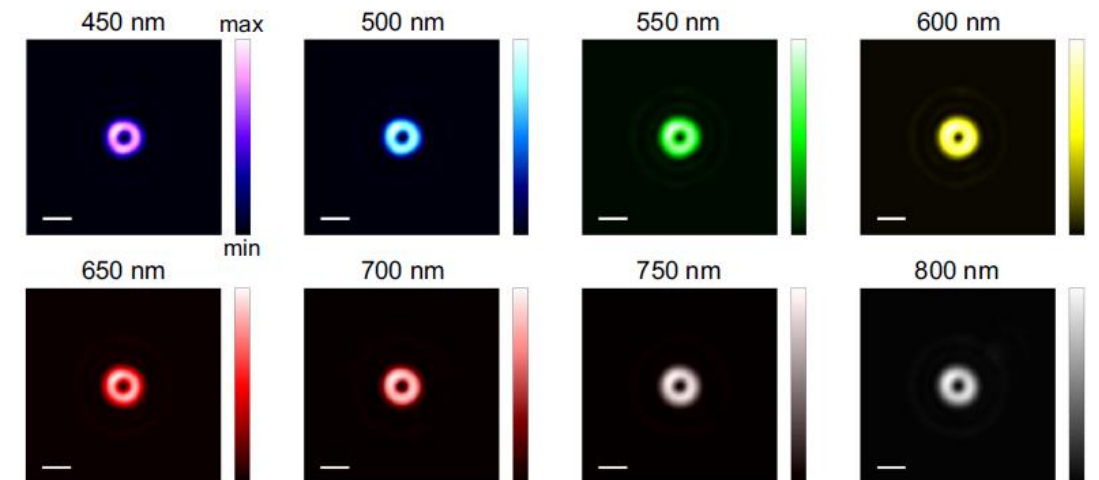
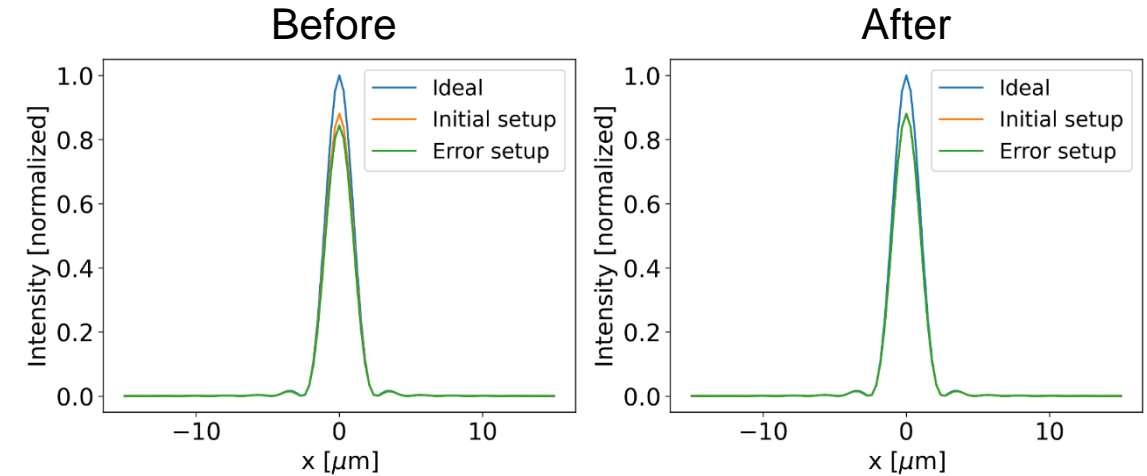
→ Better performance for inhomogeneous offsets



**→ Better Strehl ratio**

# Summary and outlook

- ✓ Tolerancing fundamentally different to classical optics
  - ✓ More parameters allow for more error corrections → also introduce new error sources
  - ✓ We can handle homogeneous and inhomogeneous distribution of offsets due to gradient-based technique
  - ✓ Define loss function for your problem
- 
- ❑ Optimization of supercells to consider near-field couplings
  - ❑ Topology optimization combined with Fourier analysis for large-area metasurfaces
  - ❑ Plasmonic metalenses or multi-layers of alternating metal and dielectric layers
  - ❑ Achromatic metalens-design, Multi-foci, ...





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# Tolerance effects: Effect of field

What happens including errors not taken into account in optimization?

- Usually still better since WFE is smaller
- Here, up to roughly 5° better, later worse
- Adding field → cannot be included via gradient (symmetry)  
→ Hessian for optimization necessary

